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Study on the Preparation and Test of Hydrodynamic Focusing Microfluidic Chip Fabricated by Liquid Crystal Display Mask Photo-Curing Method

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ABSTRACT Microfluidic chips with the function of hydrodynamic focusing is widely used in the field of cell electroporation, droplet formation, drug screening and particle enrichment. Due to the small channel size of microfluidic chip, the existing processing methods have the defects of high fabrication cost or low dimensional consistency, the drawback is particularly prominent at small fabrication quantity. In this study, hydrodynamic focusing microfluidic chip was successfully fabricated by Liquid Crystal Display (LCD) mask photo-curing method with high efficiency and precision, the mechanism of curing parameters on the accuracy of microstructure was investigated, the hot pressing process was proposed to realize the bonding of cured photosensitive resin and glass substrate. By analyzing the focusing width of typical cross structure channel, a hydrodynamic focusing chip was designed. The effects of exposure time and single layer thickness on whole curing time was studied, the factors affecting the surface roughness were investigated, and the dimensional accuracy control method was proposed. The effect of bonding pressure on cured resin temperature was calculated and tested. The focusing width was verified by theoretical calculation and experiment. The mechanism for the inconsistency between the experimental focusing width and the theoretical focusing width was analyzed. The research proposed a solution of microfluidic design, fabrication, bonding and testing, which could provide a theoretical and methodological support for the efficient fabrication of microfluidic chips.

INDEX TERMS Hydrodynamic focusing, microfluidic chip, LCD mask photo-curing, exposure time, bonding.

NOMENCLATURE

w_0	width of the outlet channel (m)	γ	velocity ratio
w_i	width of the inlet channel (m)	T	instantaneous temperature ($^{\circ}\text{C}$)
w_s	width of the side channel (m)	t	time (s)
w_f	focused width of the fluid (m)	a	thermal diffusivity ($\text{W}\cdot\text{m}^{-1}\cdot^{\circ}\text{C}^{-1}$)
h	height of channel (m)	\dot{Q}	heat generation rate per unit volume ($\text{W}\cdot\text{m}^{-2}$)
Q_i	volumetric flow rate of the inlet channel ($\mu\text{L}\cdot\text{min}^{-1}$)	ρ	material density ($\text{kg}\cdot\text{m}^{-3}$)
Q_{s1}	volumetric flow rate of side channel 1 ($\mu\text{L}\cdot\text{min}^{-1}$)	c	specific heat capacity ($\text{J}\cdot\text{kg}^{-1}\cdot\text{W}^{-1}$)
Q_{s2}	volumetric flow rate of side channel 2 ($\mu\text{L}\cdot\text{min}^{-1}$)	∇	Laplacian operator
		σ	the total stress
		D^{el}	the fourth-order elasticity tensor
		ε^{el}	the total elastic strain

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θ	interface thermal resistance ($^{\circ}\text{C}^{-1}\cdot\text{W}$)
k_1	thermal conductivity of contacting body 1 ($\text{W}\cdot\text{m}^{-1}\cdot^{\circ}\text{C}^{-1}$)
k_2	thermal conductivity of contacting body 2 ($\text{W}\cdot\text{m}^{-1}\cdot^{\circ}\text{C}^{-1}$)
σ_1	roughness of contacting body 1 (μm)
σ_2	roughness of contacting body 2 (μm)
E_1	elastic modulus of contacting body 1 (MPa)
E_2	elastic modulus of contacting body 2 (MPa)
ν_1	Poisson's ratio of contacting body 1
ν_2	Poisson's ratio of contacting body 2
C_d	curing depth (m)
D_d	single layer thickness (m)
E_0	the maximum surface exposure intensity ($\text{cd}\cdot\text{m}^{-2}$)
E_c	exposure density ($\text{cd}\cdot\text{m}^{-2}$)
P_L	the power of UV light (cd)
W_0	the spot radius (m)
V_s	the exposure speed ($\text{m}\cdot\text{min}^{-1}$)

I. INTRODUCTION

Microfluidic chips with the function of hydrodynamic focusing is widely applied in the field of cell electroporation, droplet formation, drug screening and particle enrichment [1]–[6]. The dimension of microchannels and components inside the microfluidic chip ranges from several microns to hundreds of microns. Existing fabrication methods of microfluidic chips including hot embossing, micro-injection molding, cast molding, laser abscission, and LIGA (Lithographie, Galanoformung and Abformung) method, these solutions either have the defects of high cost, low efficiency or high requirements for equipment. For example, the development cost of mold for micro injection molding or hot embossing usually ranges from US \$10000 to US \$100000 and the development cycle usually takes one to several months, while the LIGA technology relies on expensive equipment and complex operation process, which is especially unfriendly for the fabrication of microfluidic chips in small and medium quantities [7], [8].

Additive manufacturing technology [9], [10] has the advantages of cost effective and flexibility, which is an ideal method for microfluidic chip preparation, especially in the case of small fabrication quantity. Some miniaturized microfluidic chips have been fabricated by additive manufacturing technology, such as functional structure, microvascular networks and scaffolds. However, the additive manufacturing also has the defects of low dimensional accuracy or poor surface quality, especially in the preparation of micro scale structures [11]. Currently, the additive manufacturing method used for microfluidic chip processing mainly includes fused deposition manufacturing and ultraviolet (UV) curing methods, each method contains many branches. Dang *et al.* [12] presented a simple method to fabricate a new microfluidic-based multiplexed biosensing device by combining the FDM and the molding process. The device is an integration of normally closed microfluidic valving units

which offer superior operational flexibility by using polydimethylsiloxane (PDMS) membrane and require minimized energy input. The cross-section shape and surface roughness of printed structures have not been investigated, which has a significant influence on the performance of the chip. Frederik *et al.* [13] developed two exemplary microfluidic gradient generators with a channel width and height of 800 μm and 600 μm . The designed microfluidic chip was successfully printed by a commercial benchtop stereolithography printer with a single layer thickness of 50 μm . However, the variation of surface roughness was not investigated, and the high layer thickness makes it difficult to control the channel size. Hamad *et al.* [14] demonstrate a fabrication method for fully printed microfluidic systems with sensing elements using inkjet and stereolithographic 3D-printing. Three dimensions of the microfluidic channel was printed using the polyvinylpyrrolidone-co-polymethylmethacrylate (PVP-co-PMMA) ink onto the PQA1M (Teijin Du Pont Films) substrate, after bonding, the fabricated device without any further surface modification can be used on blood test. Although the fabrication process of the chip is simplified, it is easy to cause channel blockage during the bonding process caused by the flow of photosensitive resin. Moreover, many new additive manufacturing methods for micro/nano structures have been developed, including micro stereolithography, two-photon lithography, near-field direct writing and so on [15]–[18]. The micro stereolithography and two-photon lithography method are more suitable for the mold fabrication of PDMS material chip. The near-field direct writing method can control the channel size conveniently, which have potential application value in microfluidic chip fabrication, however, the cross-section shape of the channel is difficult to control [19].

The above research proved that additive manufacturing method is feasible in the field of microfluidic machining, the UV curing method has higher fabrication accuracy than the fused deposition manufacturing method. In addition, the existing research mainly focuses on the realization of microfluidic function, but the influence of printing accuracy on the focusing width was rarely analyzed before. Therefore, it is necessary to study the fabrication methods of hydrodynamic focusing microfluidic chip with micron scale channels, develop new UV curing method with controllable cross-section size and high surface quality, as well as high fabrication efficiency. In addition, the convenience of chip bonding process is also an important factor to be considered.

In this study, a low cost and convenient preparation method of microfluidic chips with high precision was proposed. A hydrodynamic focusing microfluidic chip was designed and successfully fabricated by using a self-developed desktop LCD mask photo-curing machine based on UV curing principle, and the factors influencing the hydrodynamic focusing effect were analyzed. Firstly, the focusing width of hydrodynamic focusing microfluidic chip was verified by theoretical calculation. Secondly, the effects of exposure time and single layer thickness on whole printing time was studied, the

TABLE 1. Hydrodynamic parameters of the liquid used in the experiment.

Parameter	Value
Density (kg·m ⁻³)	1000
Viscosity at 25 °C (mpa·s)	1.005
Dynamic viscosity (m ² ·s ⁻¹)	1.010×10 ⁻⁶

factors affecting the surface roughness were investigated, and the dimensional accuracy control method was proposed. The effect of bonding pressure on resin temperature was investigated. Thirdly, the causation for the inconsistency between the experimental focusing width and the theoretical focusing width was analyzed. The research proposed a solution of microfluidic design, fabrication, bonding and testing, which could provide a theoretical and methodological support for the efficient fabrication of microfluidic chips.

II. EXPERIMENTS

A. THEORETICAL CALCULATION OF HYDRODYNAMIC FOCUSING CHIP

The schematic illustration of symmetric hydrodynamic flow focusing of rectangular section channel is shown in Figure 1. According to the analysis of Lee *et al.* [20], the focusing width can be obtained by solving its numerical solution through the following formula,

$$\frac{w_f}{w_0} = \frac{Q_i}{\gamma(Q_i + Q_{s1} + Q_{s2})} \tag{1}$$

$$\gamma = \frac{\left\{ 1 - (192h/\pi^5 w_f) \sum_{n=0}^{\infty} \frac{1}{(2n+1)^5} \frac{\sinh[(2n+1)\pi w_f/2h]}{\cosh[(2n+1)\pi w_0/2h]} \right\}}{\left\{ 1 - (192h/\pi^5 w_0) \sum_{n=0}^{\infty} \frac{\tanh[(2n+1)\pi w_0/2h]}{(2n+1)^5} \right\}}$$

where γ is the velocity ratio, w_0 is the width of the outlet channel, w_i is the width of the inlet channel, w_s is the width of the side channel, w_f is the focused width of the fluid, h is the height of channel, Q_i is the volumetric flow rate of the inlet channel, Q_{s1} and Q_{s2} is volumetric flow rate of side channel 1 and 2, respectively.

B. MATERIALS AND SAMPLE PREPARATION

The liquid used in the hydrodynamic focusing test is purified water mixed with different colors of ink, the hydrodynamic parameters are shown in Table 1.

The physical and chemical parameters of photosensitive resin (CREALITY, Co., Ltd, China) parameters used in the experiment is shown in Table 2. The cured resin has good light transmittance and high mechanical strength, which can guarantee the chip’s optical properties and mechanical requirements [21].

The optical glass wafer (D-ZK3, CDGM GLASS Co., Ltd, Chengdu, China) [21], with a 76.2 mm length, 25.4 mm width and 0.8 mm thickness was used in the experiment. The material is dense barium crown optical glass with a transition temperature of 511 °C, which can ensure the stability of

TABLE 2. Photosensitive resin parameters applied in experiments.

Photosensitive resin parameters	Range
Shrinkage rate (%)	3.72-4.24
Solidification wavelength (nm)	355-410
Thermal deformation temperature(°C)	80
Viscosity at 25 °C (mpa·s)	150-200

TABLE 3. Thermo-mechanical properties of glass, polymer and mold [23].

Materials	Glass	Polymer	Stainless steel
Density (Kg·m ⁻³)	2990	1048	7800
Elastic modulus (GPa)	83.6	2.48(20 °C) 2.25(70 °C)	210
Thermal conductivity (W·m ⁻¹ ·°C ⁻¹)	1.028	0.15	44
Specific heat (J·kg ⁻¹ ·°C ⁻¹)	910	72	502
Linear expansion coefficient (°C ⁻¹)	7.2×10 ⁻⁶	6.7×10 ⁻⁶	12.2×10 ⁻⁶
Poisson ratio	0.28	0.31(20 °C) 0.40(70 °C)	0.3

physical and chemical properties during bonding process. The thermo-mechanical properties of the cured polymer were tested systematically, while the thermo-mechanical properties of glass and the stainless steel have been obtained in our previous research, as shown in Table 3 [22].

C. SIMULATION OF BONDING PROCESS

In order to determine the mechanism of bonding parameters on the bonding effect of microfluidic chips, a temperature-displacement coupling simulation of bonding process was carried out. The governing differential equation of unsteady heat conduction can be expressed as [23]

$$\frac{\partial T}{\partial t} = a\nabla^2 T + \frac{\dot{Q}}{\rho c} \tag{3}$$

where T denotes the instantaneous temperature, t gives the time, a is thermal diffusivity, \dot{Q} gives the heat generation rate per unit volume, ρ is the material density, c is the specific heat capacity, ∇ is Laplacian operator.

The linear elastic constitutive model considering temperature variation was applied to the thermal mechanical coupling simulation. The total stress is defined from the total elastic strain as,

$$\sigma = D^{el} \varepsilon^{el} \tag{4}$$

where σ is the total stress, D^{el} is the fourth-order elasticity tensor, ε^{el} is the total elastic strain.

An interface thermal resistance model [22] was adopted to calculate the effect of temperature and pressure on interface thermal resistance between glass, cured resin and stainless steel.

$$\theta = \frac{2.55(k_1 + k_2)(E_1 E_2)^{\frac{1}{3}}(\sigma_1^2 + \sigma_2^2)^{\frac{5}{6}}}{P^{\frac{1}{3}} k_1 k_2 [(1 - \nu_1^2) E_2 + (1 - \nu_2^2) E_1]^{\frac{1}{3}}} \tag{5}$$

where θ is the interface thermal resistance, k_1, k_2 refer to the thermal conductivity of the contacting bodies, σ_1, σ_2 are the contact roughness, E_1, E_2 are the elastic modulus, and ν_1, ν_2 are the Poisson's ratio.

D. CHARACTERIZATION AND INSTRUMENTS

A self-developed LCD mask photo-curing machine was adopted for light curing process, the machine includes platform, Z axis, material trough and LCD panel. The cured parts attach to the platform during the curing process, the Z axis controls the platform movement, and the photosensitive resin is laid out on the material trough. Figure 2 is the schematic diagram of LCD mask photo-curing machine, the incident position of light source can be controlled by LCD panel, the light source is homogenized by Fresnel lens. The minimum resolution of the LCD panel is 5 μm , the Z axis resolution is 1.5 μm . The minimum single layer printing thickness can be reduced to 10 μm , and the maximum curing speed is 20 $\text{mm}\cdot\text{h}^{-1}$. Minimal single layer printing thickness can reduce the shape error of the cured parts and improve the surface quality, which is beneficial to the accurate preparation of microchannel.

The UV light was adopted as the light source, the absorption of UV light by photosensitive resin accords with Beer-Lambert theorem, The energy of UV light decreases exponentially with the depth of irradiation. When the energy density is greater than the critical exposure density E_c of the photosensitive resin, the photosensitive resin will solidify. The curing depth D_d can be expressed as,

$$D_d = D_d \ln \frac{E_0}{E_c} \quad (6)$$

The intensity of UV light source accords with Gaussian distribution theorem, the maximum surface exposure intensity E_o is

$$E_o = \sqrt{\frac{2}{\pi}} \frac{P_L}{W_0 V_s} \quad (7)$$

where D_d is the single layer thickness, P_L is the power of UV light, W_0 is the spot radius, V_s is the exposure speed [24], [25].

A self-developed hot press machine was applied for bonding process, the machine includes upper heating plate, lower heating plate and manual control area. The maximum pressure is 40 MPa, the maximum heating temperature is 300 $^{\circ}\text{C}$, and the temperature control error is less than 1 $^{\circ}\text{C}$. The bonding process parameters are controlled by a computer connected to the machine. The temperature-displacement coupling simulation of bonding process was carried out by using the commercially available FEM code ABAQUS. The schematic diagram of temperature-displacement coupling simulation model is shown in Figure 3. The bonding pressure was controlled by the upper heating plate, while the lower heating plate remained fixed. The temperature of the contact surface between glass and resin was observed.

A test method was developed to evaluate the numerical results by installing a micro thermocouple probe between the

interfaces of bonded parts. The micro thermocouple probe is cylindrical with a diameter of 0.3 mm and length of 2 mm, respectively. The detection accuracy of micro thermocouple is 0.1 $^{\circ}\text{C}$. The temperature rise curves with different loading pressure were collected and stored by digital temperature recorder (Dongtai iredi Technology Co., Ltd, China), which could be compared with the simulation results. In order to ensure that the bonding pressure was not affected by the micro thermocouple, the cured chip was reserved with a micro hole to place the sensor. The diagram of the test system is shown in Figure 4.

The test system of microfluidic chip is shown in Figure 5, during the hydrodynamic focusing test, the liquid is pushed into the microfluidic chip channel through the syringe driven by the micro injection pump (XFP02-B, Suzhou iFLYTEK Scientific Instrument Co., Ltd, China), the liquid flow rate is controlled by micro injection pump. The video of the fluid focusing process is obtained by the combination of optical module and high-speed CCD (815UM, Weihong image Co., Ltd, China), and transmitted to the laptop. The field light intensity is controlled by an LED light. The surface roughness of cured part was observed by the laser microscope (VHX-1000, KEYENCE Co., Ltd, Japan) with display resolution of height 0.005 μm and width 0.01 μm . The numerical solution of the focusing width was obtained by MATLAB 2018 (Mathworks Inc, America) software.

III. RESULTS AND DISCUSSION

A. DESIGN OF HYDRODYNAMIC FOCUSING CHIP

According to the equation 1 and 2, the focusing width is mainly related to the velocity and width of the channel, and the channel depth mainly affects the flux of the focused liquid. A hydrodynamic focusing microfluidic chip with three dimensional dimensions of 55 mm length, 25.4 mm width and 3 mm thickness was designed, the focusing chip includes three inlets and outlets respectively. The channel width of the chip is 300 μm and the height is 350 μm , as shown in Figure 6.

B. INFLUENCE OF UV CURING PARAMETERS ON MICROFLUIDIC CHIP CHANNEL ACCURACY

Before preparing the designed microfluidic chip, it is necessary to investigate the influence of curing parameters on printing time, surface quality and shape accuracy. The effects of exposure time and single layer thickness on whole printing time is shown in Figure 7. The experimental results demonstrate that increasing the single layer thickness can reduce the whole printing time significantly, and the exposure time does not play a major role in the whole printing time.

The relationship between UV exposure time and surface roughness of cured parts at different single layer thickness is shown in Figure 8. When the thickness of single layer printing is less than 20 μm , the final surface roughness first decreases and then slightly increases, the experiment proved that small single layer thickness cannot guarantee good surface quality. If the UV exposure time is less than 2 s, the photosensitive

resin cannot be fully cured, resulting in high surface roughness. With the increase of exposure time, the surface roughness decreases sharply. When the exposure time is 6 s, the surface roughness decreases to the minimum of 0.171 μm . Once the exposure time is more than 6 s, the whole microstructure cannot be fabricated. After considering the two factors of printing efficiency and printing accuracy, the exposure time of 6 s and the printing thickness of 50 μm were adopted to fabricate the designed hydrodynamic focusing microfluidic chip.

Based on the analysis of equation 6 and 7, the attenuation of light source energy density has a significant effect on the shape of cured parts. In addition, the volume shrinkage of the photosensitive resin during the curing process and the movement accuracy of the equipment will affect the dimensional accuracy of the cured parts. Therefore, there will have a certain deviation between the designed size and the actual preparation size during the LCD mask photo-curing process. In order to accurately prepare the rectangular microgroove with the target size, it is necessary to analyze the corresponding relationship between the designed size and the actual microchannel size. In the experiment, the exposure time was 6 s, each experiment was conducted for three times, the size error of cured rectangular microchannel is less than 0.02 μm , and the tested results are fitted in a straight line, as shown in Figure 9. The straight line fitting formulas of width and height are $y = 0.915x - 38.467$ and $y = 0.871x - 21.867$, while the R square is 0.964 and 0.989, respectively. The results show that the repeatability error of width and height direction are very small when the curing parameters keep consistent. The minimum channel size that can be machined by LCD mask photo-curing method can reach 100 μm , and the surface quality are significantly better than correlational research reported recent years [26]–[28].

According to the above research, a rectangular cross-section microfluidic chip with a width of 300 μm and a depth of 350 μm was prepared. The micrograph of the fabricated microfluidic chip is shown in Figure 10(a), the size of the channel is uniform, but there are smaller arcs at the cross of the channel, the reason for this phenomenon is that the spot radius is fixed during the curing process, it is unable to reduce the spot radius according to the structure shape, resulting in incomplete curing at the corner. Except the cross position, the cured microchannel has high size consistency, the three-dimensional structure of the channel is shown in Figure 10(b). The cross-section shape of the microchannel is shown in Figure 10(c), the results indicated that after curing parameter adjustment, the LCD mask photo-curing machine can realize high precision fabrication of microchannel.

C. EFFECT OF BONDING PRESSURE ON HEATING TEMPERATURE OF PHOTOSENSITIVE RESIN

The surface roughness of stainless steel, cured resin and glass is 1.6 μm , 0.171 μm and 0.01 μm , respectively. Based on the equation 5, the effects of pressure on interface thermal resistance is obtained, as shown in Figure 11. The curves

indicate that there is a negative correlation between contact pressure and thermal resistance coefficient. In addition, low surface roughness is more conducive to the reduction of thermal resistance coefficient

The comparison of the temperature rises of resin at different bonding pressure is shown in Figure 12. During the experiment, the temperature of the upper and lower heating plates of the hot press machine was kept at 80 $^{\circ}\text{C}$, and the test chip was heated as soon as it was put in. Therefore, only the temperature rise date after the microfluidic chip was stably applied pressure was extracted. The simulation results and tested results both confirmed that the resin temperature rises rapidly with the increase of bonding pressure. The increased bonding pressure reduces the interface thermal resistance between the heating platform, resin and glass. However, the increase of pressure has no obvious effect on the total heating time. Therefore, it is not necessary to blindly increase the pressing pressure during bonding process, which is beneficial to reduce the channel deformation of microfluidic chip. It should be noted that the rising speed of temperature in the experiment is slower than that in the simulation, and it is necessary to continue to optimize the thermal resistance model in the follow-up research. Besides, the effect of bonding pressure on bonding strength of glass and cured resin needs to be further investigated.

Based on the simulation and test result, the prepared microfluidic chip was fixed on the glass substrate by hot bonding process. The bonding temperature is 80 $^{\circ}\text{C}$, the bonding pressure is 0.2 MPa, and the holding time is 1 hour. The chip inlet and outlet were connected by ruhr connector, and the connectors were glued together. The assembled microfluidic chip is shown in Figure 13. By water injection test, the glass substrate and the cured resin microfluidic chip were well bonded without leakage.

The core equipment of the whole hydrodynamic focusing chip preparation is a simple desktop device. It can be completed by printing, cleaning and bonding process, the overall process shows the superiority of high efficiency and cost-effectively [29]–[31].

D. HYDRODYNAMIC FOCUSING EXPERIMENT

The experimental images of the symmetric hydrodynamic focusing effect in microchannel with different flow rate ratios are shown in Figure 14. Different from the theoretical model, there is a certain fillet in the cross position of the microfluidic chip fabricated by LCD mask photo-curing method, the fillets may affect the focus width.

The comparison of focusing width of theory and experiment result under different flow rate ratios is shown in Figure 15. The variation trend of focusing width is consistent with the theoretical calculation, but there is a certain gap between the experimental results and the theoretical results of hydrodynamic focusing. When the flow rate ratio is less than 1, the experimental focusing width is larger than the theoretical calculation width, once the flow rate ratio is greater

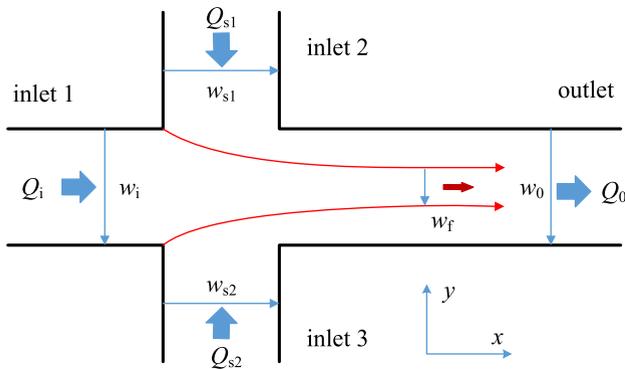


FIGURE 1. Schematic illustration of symmetric hydrodynamic flow focusing.

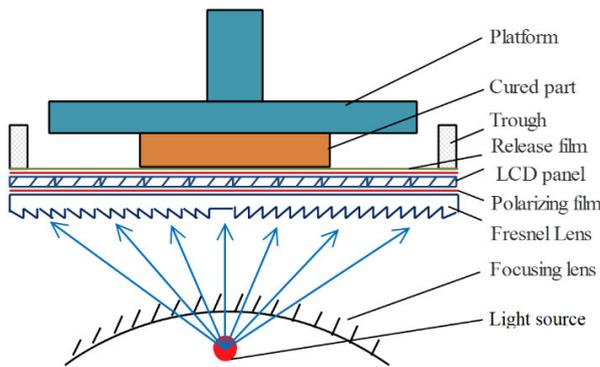


FIGURE 2. Schematic diagram of self-developed LCD mask photo-curing machine.

than 1, the experimental focusing width is smaller than the theoretical calculation.

In order to analyze the reasons for the inconsistency between the experimental focusing width and the theoretical focusing width, the influence of microchannel width on focusing width at different flow rate ratios are investigated by simultaneous equation 1 and 2, as shown in Figure 16. During the calculation, the flow rate and microchannel depth of inlet 1 remain constant. It can be seen from the results that there is a linear relationship between the channel width and the focus width. When the flow rate ratio is less than 1, the focus starting position is far away from the inlet 1. Because of the existence of fillet at the junction, the actual channel width is larger than the designed width, resulting in the increase of focus width. Otherwise, the actual focus width is reduced.

Due to the limitation of LCD screen resolution and equipment motion accuracy, it is difficult to eliminate the fillet at the intersection of micro channels. In the follow-up study, the corner radius of microchannel will be reduced by increasing the resolution of LCD screen to 4K and improving the accuracy of the motion system. In addition, developing the resin with lower shrinkage is also a major means to improve printing accuracy, which needs further efforts.

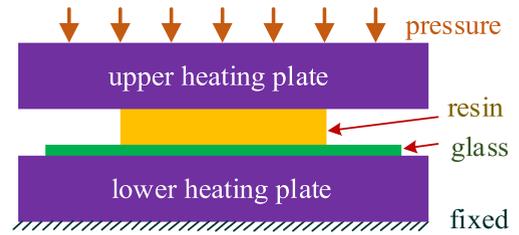


FIGURE 3. Schematic diagram of temperature-displacement coupling simulation model.

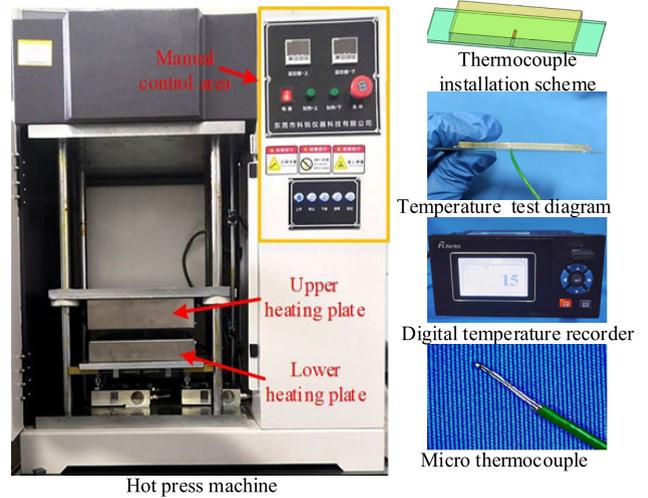


FIGURE 4. Diagram of temperature curve acquisition method.

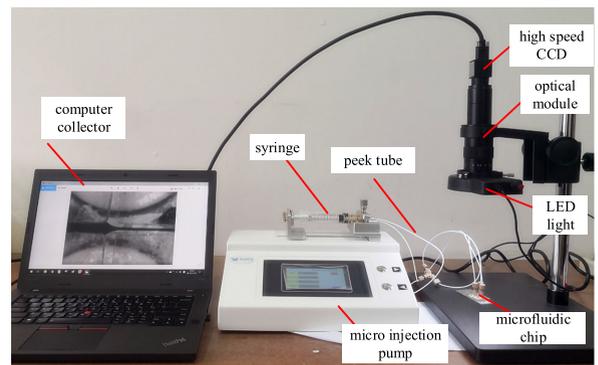


FIGURE 5. The test system of hydrodynamic focusing microfluidic chip.

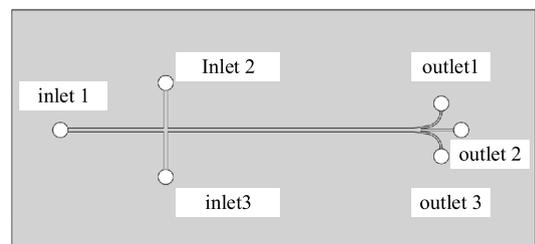


FIGURE 6. Schematic diagram of designed hydrodynamic focusing microfluidic chip.

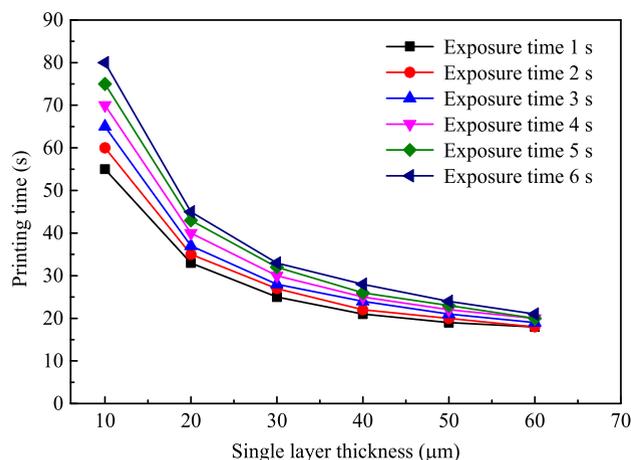


FIGURE 7. The effects of exposure time and single layer thickness on whole printing time.

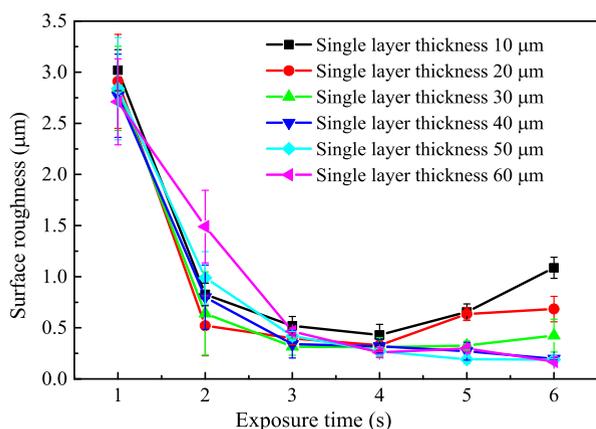


FIGURE 8. Relationship between UV exposure time and surface roughness.

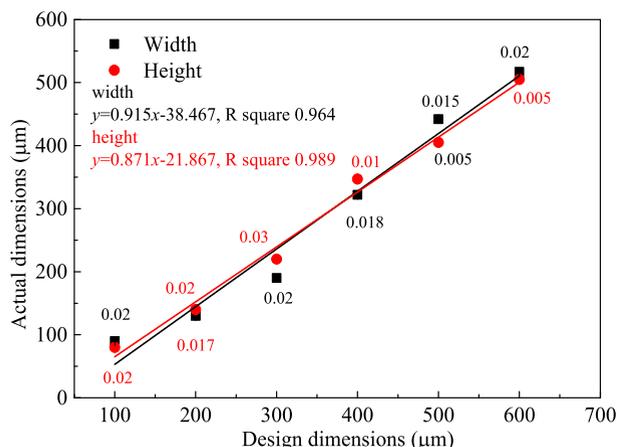


FIGURE 9. Relationship between design dimensions and actual dimensions.

IV. CONCLUSION

This research provided a low-cost, fast and high-precision microfluidic chip preparation method for small and medium-batches. The hydrodynamic focusing microfluidic chip with a

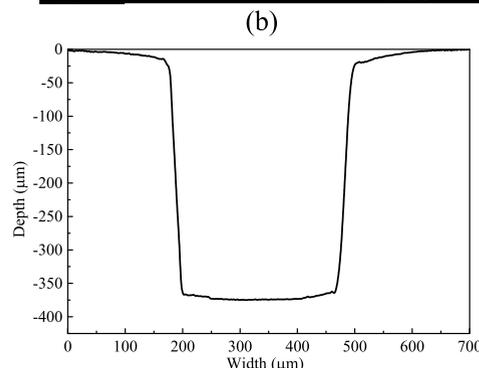
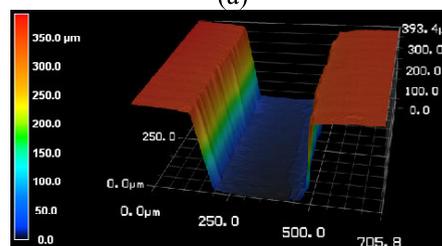
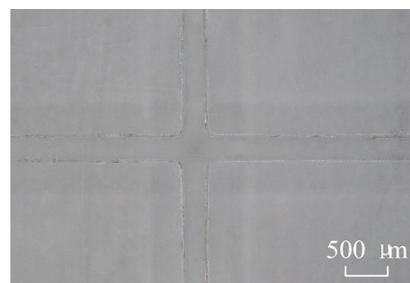


FIGURE 10. The fabricated microfluidic chip: (a) micrograph photograph, (b) three-dimensional structure, and (c) the cross-section shape.

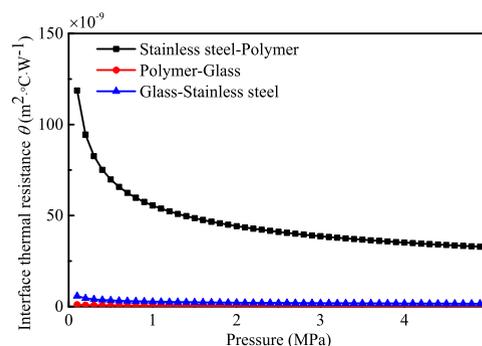


FIGURE 11. Effects of pressure on interface thermal resistance.

width of 300 μm and depth of 350 μm was designed and fabricated by using a self-developed desktop LCD mask photocuring machine, then bonded with hot pressing method. The mechanism of curing parameters on the accuracy of microstructure was investigated, the surface roughness of the cured parts could be minimized to 0.171 μm with an exposure time of 6 s. The cured resin was well bonded on glass substrate at a bonding temperature of 80 °C, and bonding

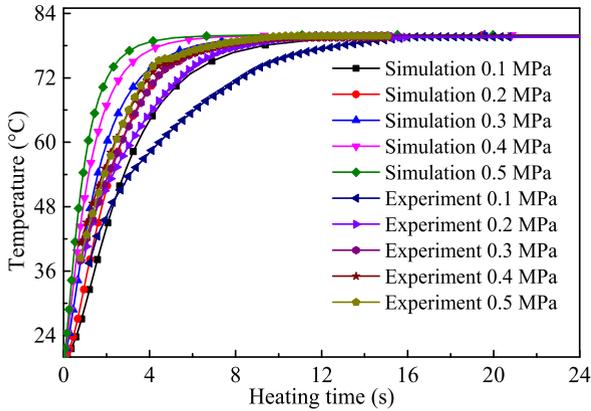


FIGURE 12. Comparison of the temperature rise of resin at different bonding pressure.

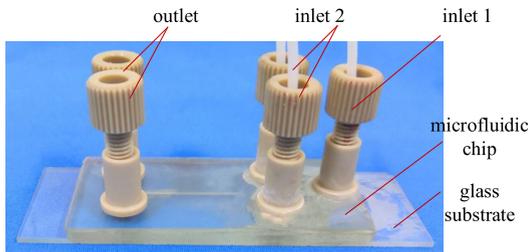


FIGURE 13. Fabricated microfluidic chip after bonding.

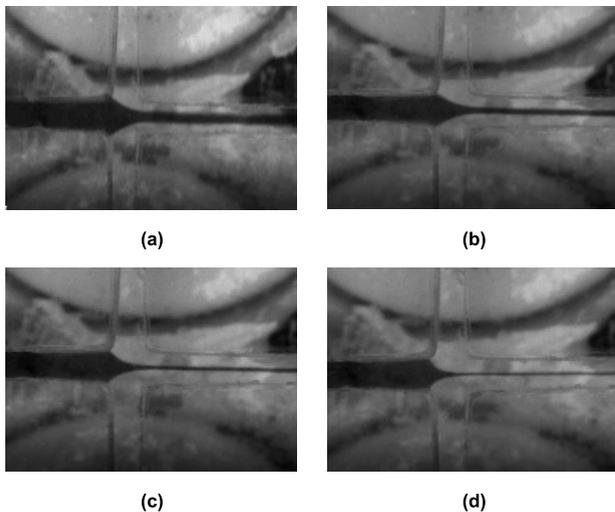


FIGURE 14. Experimental images of the symmetric hydrodynamic focusing effect in microchannels with different flow rate ratios (Q_s/Q_i): (a) $Q_s/Q_i = 0.5$, (b) $Q_s/Q_i = 1.0$, (c) $Q_s/Q_i = 1.5$, (d) $Q_s/Q_i = 2.0$.

pressure of 0.2 MPa for 1 hour. The inconsistency between the experimental focusing width and the theoretical focusing width was mainly caused by the fillet at the junction of the cured channel. The fabrication methods mentioned above should facilitate the prototyping of devices for microfluidics, and conducted to the rapid development of the microfluidics. In addition, the following research should further improve the preparation accuracy of complex structure shape, such

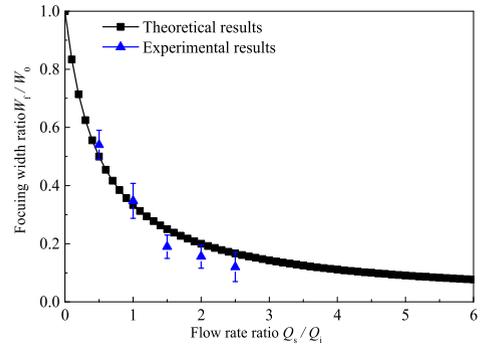


FIGURE 15. Comparison of focusing width of theoretical calculation and experiment result under different flow rate ratios.

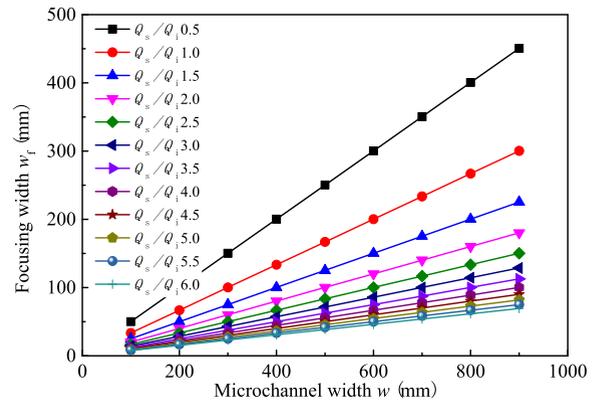


FIGURE 16. The influence of microchannel width on focusing width at different flow rate ratios.

as increasing LCD screen resolution, reducing the volume shrinkage of photosensitive resin and improving the motion accuracy of LCD mask photo-curing machine.

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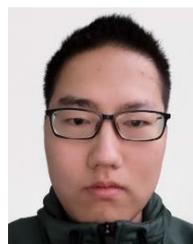
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